CONFIDENTIAL

# Physical properties of KGK SAR25C12

KGK Chemical Corp.

KGK Chemical Corp.

©2020 KGK Chemical Corp. All Rights Reserved.

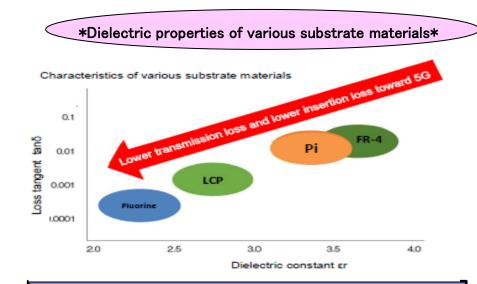
2020/7

# For 5G 《Connected Car/IoT》 ~Required FPC substrate materials~

\*Low dielectric, power saving, low heat generation, low noise

\*Low frequency dependence

\*High thermal conductivity



# Conventional polyimide film absorbs moisture a lot.



## Film forming technology for liquid crystal polymers

《KGK's original film forming technology》

A Technology for removing the orientation of LCP by solution casting (solvent molding) instead of melt molding.



## KGK's strengths Integrated production from LCP to FCCL





#### Conventional

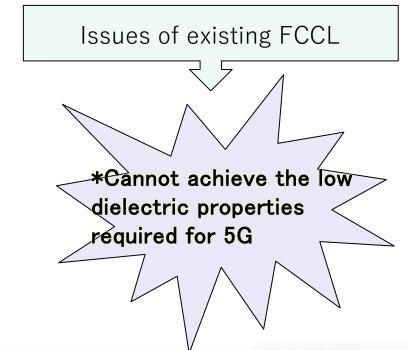
PI
Copper foil

Uses PI film with heat resistance and insulation

#### Existing FCCL configuration 1

LCP
Epoxy adhesive
Copper foil

# Fused LCP film Adhesion to copper foil with epoxy adhesive



#### Existing FCCL configuration<sup>(2)</sup>



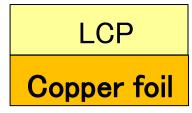
#### CONFIDENTIAL

## KGK SAR25C12 Date

Thickness (um)		Cu		12
		LCP	25	
		Cu		-
Technical Data (		Roughness of Resist Side(um)	Ra	0.25
	Cu		Rz	1.03
		Roughness of Lami Side(um)	Ra	0.25
			Rz	1.03
		Tensile Strength(MPa)	As Produced	330
			After Annealed	250
		Elongation (%)	As Produced	16
			After Annealed	20
	LCP	Tg (°C)		250
		CTE (ppm/K)		36(TMA)
		Tensile Strength (MPa)		8.7×10 <sup>1</sup>
		Tensile Modulus (GPa)		8.7×10 <sup>-2</sup>
		Elongation (%)		11%
Technical Data		Moisture Absorption (%)		< 0.1
		Dk (10GHz)		3.39
		Df (10GHz)		0.0039
		Insulation Resistance (Ω)		5.6×10 <sup>10</sup>
		Volume Resistivity (Ω)		2.0×10 <sup>12</sup>
		Surface Resistance (Ω)		5.6×10 <sup>10</sup>
		Voltage Breakdown (V/um)		200

KGK Chemical Corp.

## **«KGK FCCL features»**



New FCCL

configuration

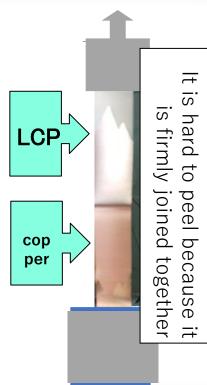
- LCP with low dielectric properties is used as an insulating material.
- By forming a film on copper foil, no adhesive is required, and it has low dielectric properties of LCP.

## KGK original 5G compatible technology

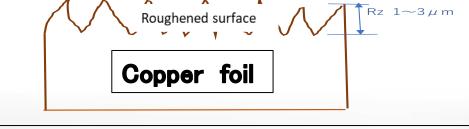


## <Original direct cast film forming method>

 A strong integral bond can be obtained without an epoxy adhesive during LCP-copper interface.
Since there is no uneven semiconductor (roughened surface) on the copper foil surface, dielectric loss can be avoided.



Previous: Roughening required → KGK: Roughening unnecessary





## Can be thinned by KGK's original manufacturing method

CONFIDENTIAL

Item	Unit	Method	Conditions	SAR25C12 (KGK)	Other's
Cu	μm	-	-	12	12
LCP	μm	-	-	25	100
Solder heat resistance	_	-	270°C、30sec.	0	0
Dk (20GHz)	-	Split post dielectric resonator method	20GHz	3.63	3.58
Df(20GHz)	_	Split post dielectric resonator method	20GHz	0.0057	0.0020
Dk (10GHz)	_	Cavity resonance method	10GHz	3.39	3.50
Df (10GHz)	_	Cavity resonance method	10GHz	0.0039	0.0018
Tensile Modulus	GPa	ASTM D882	23°C	0.087GPa	0.16GPa
Volume Resistivity	Ωcm	JIS-C-2151		E+17	E+16
Moisture Absorption	%	_	85 ℃×85% RH×168h	<0.1	<0.1
Peel Strength	N/mm	JIS C 6471		>1.4	0.8
Chemical resistance	-	_	(HCI,NaOH,IPA) 23°C 5min.	No abnormality	No abnormality
Linear expansion (MD)	ppm/K	ТМА	50−150°C	36	52
Linear expansion (TD)	ppm/K	ТМА	50-150°C	36	84
Flame retardance	-	UL94		V-0	V-0
	No a	nisotropy (strength differend	Firmly adhere	d by direct c	oating meth



© 2020 KGK Chemical Corporation Co., Ltd. All Rights Reserved.

depending on direction) due to direct

CONFIDENTIAL

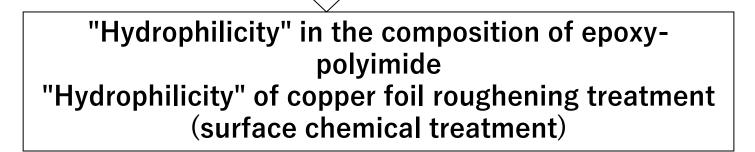
Item	Unit	Method	Conditions	SAR25C12 (KGK)	Other's
Cu	μm	_	_	12	12
LCP	μm	-	_	25	100
Solder heat resistance	-	-	270°C、30sec.	9	0
Dk (20GHz)	-	Split post dielectric resonator method	20GHz	3.63	3.58
Df (20GHz)	-	Split post dielectric resonator method	20GHz	0.0057	0.0020
Dk (10GHz)	_	Cavity resonance method	10GHz	3.39	3.50
Df (10GHz)	_	Cavity resonance method	10GHz	0.0039	0.0018

Since the dielectric constant (relative dielectric constant, dielectric loss tangent) depends on the type of material (PI, LCP, PTFE, etc.), no significant difference is seen with other companies, but studies were conducted to reduce and improve the dielectric constant. By examining the film conditions, an improvement of relative permittivity of -3.1% was seen (additional verification required).

	Item	Method	SAR25C12 (KGK)
Consider conditions	Dk (10GHz)	Cavity resonance method	-3.1%



Issues of conventional materials for 5G (autonomous driving, remote medicine, advanced IoT factory etc.)



# Solved by LCP cast film FCCL



## End of presentation

User is responsible for determining whether the KGK product is fit for a particular purpose and suitable for user's method of application. Please remember that many factors can affect the use and performance of a KGK product in a particular application. The materials to be bonded with the product, the surface preparation of those materials, the product selected for use, the conditions in which the product is used, and the time and environmental conditions in which the product is expected to perform are among the many factors that can affect the use and performance of a KGK product. Given the variety of factors that can affect the use and performance of a KGK product, some of which are uniquely within the user's knowledge and control, It is essential that the user evaluate the KGK product to determine whether it is fit for a particular purpose and suitable

for the user's method of application.

KGK make no warranties on above data.

KGK Chemical Corporation. 940 Minaminagai Tokorozawa-City saitama-Pref 359-0011 Japan Tel : +81 4 2944 5151 Mail : info-k@kgk-tape.co.jp URL : https://www.kgk-tape.co.jp/



©2020 KGK Chemical Corp. All Rights Reserved.